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41,733 Reg. No.

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:

Applicant

Thomas Wiegele et al.

Appln. No.

10/620,119

Filed

July 15, 2003

Title

MICRO MIRROR ARRAYS AND MICROSTRUCTURES

WITH SOLDERABLE CONNECTION SITES

Docket No.

015559-288

Art Unit

2874

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Pursuant to 37 C.F.R. §1.56, the Examiner's attention is directed to the references listed on the attached Information Disclosure Citation. Copies of all foreign patent documents and non-patent literature references are provided herewith.

It is to be understood that the present submission of art is in no way intended to be a waiver of any arguments or defenses available to the applicant under the rules of the U.S. Patent and Trademark Office and the statutes of the United States.

It is believed that this information disclosure statement is being filed prior to the issuance of the first Official Action and, therefore, no fee is required. However, the Commissioner is authorized to charge any fees required by this paper, including the \$180.00 fee pursuant to 37 C.F.R. §1.17(p) if applicable, or to credit any overpayment to Deposit Account No. 20-0809.

Appln. No.: 10/620,119 Docket No.: 015559-288

Information Disclosure Statement

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INFORMATION DISCLOSURE CITATION

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Docket:	015559-288	Appln. No.:	10/620,119
Applicant	: Thomas Wiegele et al.		

Group:

2874

U.S. PATENT DOCUMENTS

Filed:

July 15, 2003

Document No.	Date	Name	Class	Sub	
2003/0107794	06/2003	Siekkinen et al.			
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Examiner	Document No.	Date	Country	Class	Sub	Y_	N
	06-120336 (with English abstract)	04/1994	Japan				X
	08-106614 (with English abstract)	04/1996	Japan				X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	Graph of cure time vs. glass transition temperature for BCB (date unknown) Applicants admit the status of this graph as prior art for the limited purpose of examination of this application, but otherwise reserve the right to challenge the status of this publication as prior art.
	Statement by Applicants (including Attachment A)
	M. Jenkins, et al., "Chemical and Structural Characterization of Silane Adhesion Promoting Films for Use in Microelectronic Packaging, Materials Research Society. Symp. Vol. 629, pp. FF5.12.1-FF5.12.6 (2000)
Examiner:	Date Considered:

^{*} Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

INFORMATION DISCLOSURE CITATION

Examiner:

10/620,119 Docket: 015559-288 Appln. No.: Thomas Wiegele et al. Applicant: July 15, 2003 Group: 2874 Filed:

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of 3 Pages

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) G. Mittendorfer, et al., "Summary Study of BCB Coating Tests," by EVG (date unknown) Applicants admit the status of this publication as prior art for the limited purpose of examination of this application, but otherwise reserve the right to challenge the status of this publication as prior art. "Tutorial 1 - Introduction to Flip Chi;p: What, Why, How," web page by Flip Chips Dot Com (date of first publication unknown). Applicants admit the status of this publication as prior art for the limited purpose of examination of this application, but otherwise reserve the right to challenge the status of this publication as prior art. S. Renard, "Wafer level Surface Mountable Chip Size Packaging for MEMS and ICs," Micromachined Devices and Components VI, Proceedings of SPIE, Vol. 4176 (2000) H.H. Gatzen, "Dicing challenges in microelectronics and micro electro-mechanical systems (MEMS)," Microsystem Technologies, 7, pp. 151-154 (2001) H.H. Gatzen, et al., "Advances in Dicing Wafers for Micro Electro-Mechanical Systems (MEMS)," Proceedings Volume 2, MICRO.tec 2000, Hanover Germany (9/2000) Date Considered:

^{*} Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.